

FILM-FORMING MATERIAL

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Abstract of **JP2001192531**

PROBLEM TO BE SOLVED: To provide a proton-conductive film-forming material which exhibits a high proton conductivity in a wide temperature range, is prevented from swelling in water, and is excellent in durability. **SOLUTION:** This material comprises a polymer which contains at least 50 mol% specific repeating structural units and has sulfo groups.

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